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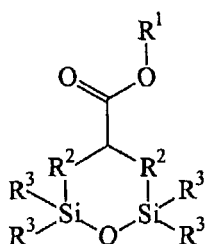
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(54) Title: NOVEL PHOTSENSITIVE BILAYER COMPOSITION



(I)

(57) Abstract: Polymers and co-polymers having monomeric units formed by the polymerization of monomers of the Structure (I), where R^1 is a moiety containing an ethylenically unsaturated polymerizable group, R^2 is a C_1 - C_3 alkylene group, and R^3 is a C_{1-10} linear or cyclic alkyl group, a C_{6-10} aromatic or substituted aromatic group, a C_{1-8} alkoxy methyl, or a C_{1-8} alkoxy ethyl group, are useful as binder resins for photosensitive compositions, and processes for photolithography in the production of semiconductor devices and materials.

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